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Chemical analysis of aluminosilicate refractory products (alternative to the X-ray fluorescence method) - Part 3: Inductively coupled plasma and atomic absorption spectrometry methods (ISO 21587-3:2007)

iTeh STANDARD PREVIEW

Chemische Analyse feuerfester Erzeugnisse aus Aluminosilicat (Alternative zum Röntgenfluoreszenzverfahren) - Teil 3: Verfahren mit induktiv gekoppeltem Plasma und Atomabsorptionsspektrometrie (ISO 21587-3:2007)

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Analyse chimique des produits réfractaires d'aluminosilicates (méthode alternative a la méthode par fluorescence de rayons X) - Partie 3: Méthodes par spectrométrie d'absorption atomique (AAS) et spectrométrie d'émission atomique avec plasma induit par haute fréquence (ICP-AES) (ISO 21587-3:2007)

Ta slovenski standard je istoveten z: EN ISO 21587-3:2007

ICS:

81.080

SIST EN ISO 21587-3:2008

en

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English Version

Chemical analysis of aluminosilicate refractory products
(alternative to the X-ray fluorescence method) - Part 3:
Inductively coupled plasma and atomic absorption spectrometry
methods (ISO 21587-3:2007)

Analyse chimique des produits réfractaires
d'aluminosilicates (méthode alternative à la méthode par
fluorescence de rayons X) - Partie 3: Méthodes par
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Atomabsorptionsspektrometrie (ISO 21587-3:2007)

This European Standard was approved by CEN on 13 September 2007.

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This European Standard exists in three official versions (English, French, German). A version in any other language made by translation under the responsibility of a CEN member into its own language and notified to the CEN Management Centre has the same status as the official versions.

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Foreword

The text of ISO 21587-3:2007 has been prepared by Technical Committee ISO/TC 33 "Refractories" of the International Organization for Standardization (ISO) and has been taken over as EN ISO 21587-3:2007 by Technical Committee CEN/TC 187 "Refractory products and materials", the secretariat of which is held by BSI.

This European Standard shall be given the status of a national standard, either by publication of an identical text or by endorsement, at the latest by March 2008, and conflicting national standards shall be withdrawn at the latest by March 2008.

This document supersedes ENV 955-4:1997.

According to the CEN/CENELEC Internal Regulations, the national standards organizations of the following countries are bound to implement this European Standard: Austria, Belgium, Bulgaria, Cyprus, Czech Republic, Denmark, Estonia, Finland, France, Germany, Greece, Hungary, Iceland, Ireland, Italy, Latvia, Lithuania, Luxembourg, Malta, Netherlands, Norway, Poland, Portugal, Romania, Slovakia, Slovenia, Spain, Sweden, Switzerland and United Kingdom.

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Endorsement notice

The text of ISO 21587-3:2007 has been approved by CEN as EN ISO 21587-3:2007 without any modifications.

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**Chemical analysis of aluminosilicate
refractory products (alternative to the
X-ray fluorescence method) —**

**Part 3:
Inductively coupled plasma and atomic
absorption spectrometry methods**

iTeh STANDARD PREVIEW

*Analyse chimique des produits réfractaires d'aluminosilicates (méthode
alternative à la méthode par fluorescence de rayons X) —*

*Partie 3: Méthodes par spectrométrie d'absorption atomique (AAS) et
spectrométrie d'émission atomique avec plasma induit par haute
fréquence (ICP-AES)*

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Published in Switzerland

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Foreword

ISO (the International Organization for Standardization) is a worldwide federation of national standards bodies (ISO member bodies). The work of preparing International Standards is normally carried out through ISO technical committees. Each member body interested in a subject for which a technical committee has been established has the right to be represented on that committee. International organizations, governmental and non-governmental, in liaison with ISO, also take part in the work. ISO collaborates closely with the International Electrotechnical Commission (IEC) on all matters of electrotechnical standardization.

International Standards are drafted in accordance with the rules given in the ISO/IEC Directives, Part 2.

The main task of technical committees is to prepare International Standards. Draft International Standards adopted by the technical committees are circulated to the member bodies for voting. Publication as an International Standard requires approval by at least 75 % of the member bodies casting a vote.

Attention is drawn to the possibility that some of the elements of this document may be the subject of patent rights. ISO shall not be held responsible for identifying any or all such patent rights.

ISO 21587-3 was prepared by Technical Committee ISO/TC 33, *Refractories*.

ISO 21587 consists of the following parts under the general title *Chemical analysis of aluminosilicate refractory products (alternative to the X-ray fluorescence method)*:

- Part 1: *Apparatus, reagents, dissolution and gravimetric silica*
- Part 2: *Wet chemical analysis*
- Part 3: *Inductively coupled plasma and atomic absorption spectrometry methods*

Chemical analysis of aluminosilicate refractory products (alternative to the X-ray fluorescence method) —

Part 3: Inductively coupled plasma and atomic absorption spectrometry methods

1 Scope

This part of ISO 21587 specifies inductively coupled plasma/atomic emission (ICP/AE) spectrometry and flame atomic absorption (FAA) spectrometry methods for the chemical analysis of aluminosilicate refractory products and raw materials.

The methods are applicable to the determination of the following:

— silicon(IV) oxide (SiO_2)

— aluminium oxide (Al_2O_3)

— iron(III) oxide (total iron oxide calculated as Fe_2O_3)

— titanium(IV) oxide (TiO_2)

— manganese(II) oxide (MnO)

— calcium oxide (CaO)

— magnesium oxide (MgO)

— sodium oxide (Na_2O)

— potassium oxide (K_2O)

— chromium(III) oxide (Cr_2O_3)

— zirconium oxide (ZrO_2)

— phosphorous(V) oxide (P_2O_5)

This part of ISO 21587 gives alternatives to the X-ray fluorescence (XRF) method given in ISO 12677:2003, *Chemical analysis of refractory products by XRF — Fused cast bead method*.

2 Normative references

The following referenced documents are indispensable for the application of this document. For dated references, only the edition cited applies. For undated references, the latest edition of the referenced document (including any amendments) applies.

ISO 21587-1:2007, *Chemical analysis of aluminosilicate refractory products (alternative to the X-ray fluorescence method) — Part 1: Apparatus, reagents, dissolution and gravimetric silica*

ISO 21587-2:2007, *Chemical analysis of aluminosilicate refractory products (alternative to the X-ray fluorescence method) — Part 2: Wet chemical analysis*

ISO 26845, *Chemical analysis of refractories — General requirements for wet chemical analysis, atomic absorption spectrometry and inductively coupled plasma methods*

3 Determination of residual silica in solution by ICP/AES

3.1 Principle

The residual silica remaining in stock solutions (S1) or (S'1) is determined using ICP/AES.

3.2 Reagents

Prepare the reagents specified in ISO 26845 and ISO 21587-1 and the following.

3.2.1 Aluminium oxide solution, Al_2O_3 5 mg/ml.

Weigh 2,65 g of aluminium (purity, more than 99,5 % by mass, having Si, less than 0,001 % by mass) into a platinum dish (e.g. 100 ml). Cover the dish with a watch glass, add approximately 100 ml of hydrochloric acid (1+1) and heat on a steam bath in order to dissolve the metal. After cooling, dilute to 1 l in a volumetric flask with water.

3.2.2 Matrix solution 1.

Transfer an appropriate aliquot portion of the aluminium oxide solution (5 mg/ml) into a 500 ml volumetric flask and dilute to the mark with water. Prepare this solution freshly whenever needed.

NOTE The amount of the aluminium oxide solution to be used is determined by the chemical composition of the sample. For example, use 35 ml for the aluminium oxide solution of a sample containing 35 % by mass of aluminium oxide.

3.2.3 Matrix solution 2 or 2'.

Carry out the procedure given in 4.2.2.3 or 4.2.3.3 of ISO 21587-1:2007 without the sample, but omit heating the fusion mixture or anhydrous sodium carbonate. The solution equivalent to stock solution (S1) or (S'1) is referred to as matrix solution 2 or 2', as applicable.

3.2.4 Series 2 solution for calibration.

Transfer appropriate amounts of aliquot portions of dilute standard silicon(IV) oxide solution (0,2 mg/ml) precisely into several 100 ml volumetric flasks, in accordance with the composition of the samples. Add 10 ml each of matrix solution 1 and either matrix solution 2 or 2', respectively, and dilute to the mark with water. Table 1 is shown as an example.

NOTE In Table 2, a typical example of the preparation of solutions is shown. Prepare an appropriate series of solutions for calibration in accordance with the compositions of the samples, and the type and capabilities of instrument used.

Table 1 — Example of Series 2 solution for calibration

Calibration solution Series 2	Matrix solution 1	Matrix solution 2 or 2'	Dilute standard silicon(IV) oxide solution	Concentration of solution
No.	ml	ml	ml	SiO ₂ mg/100 ml
1	10	10	0	0
2	10	10	1	0,2
3	10	10	2	0,4
4	10	10	5	1,0
5	10	10	10	2,0
6	10	10	15	3,0

3.3 Procedure

Determine the silicon(IV) oxide remaining in solution (S1) or (S'1) (4.2.2.3 or 4.2.3.3 in ISO 21587-1:2007) as follows.

Transfer 10 ml of stock solution (S1) or (S'1) to a 100 ml volumetric flask, and dilute to the mark with water. This solution, for the determination of dissolved silicon(IV) oxide, is referred to as diluted stock solution (S1d) or (S'1'd).

Spray a portion of diluted stock solution (S1d) or (S'1'd) into the argon plasma flame of the inductively coupled plasma/atomic emission (ICP/AE) spectrometer, and measure the emission intensity at, for example, the wavelength of 251,61 nm.

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3.4 Blank test

Carry out the procedure in 3.3 with blank solution (B1) or (B'1). The diluted blank solution equivalent to diluted stock solution (S1d) or (S'1'd) is referred to as diluted blank solution (B1d) or (B'1'd).

3.5 Plotting the calibration graph

Using the calibration solution Series 2, carry out the emission procedure described in 3.3. Plot the relation between the emission intensity and the mass of oxide, and prepare the calibration graph by adjusting the curve so that it passes through the point of origin.

A new calibration should be carried out, using the range of calibration and blank solution solutions for each set of determinations.

3.6 Calculation

Calculate the mass fraction of silicon(IV) oxide, w_{SiO_2} , as a percentage, from the amount of silicon(IV) oxide derived from the figures obtained from 3.3 and 3.4 and the calibration described in 3.5 using the equation:

$$w_{\text{SiO}_2} = \frac{(m_1 - m_2) + (m_3 - m_4) \times \frac{500}{10}}{m} \times 100 \quad (1)$$